



Proceedings H₂S and NH₃ Detection with Langmuir-Schaefer Monolayer Organic Field-Effect Transistors ⁺

Alexey Sizov ^{1,2,*}, Askold Trul ^{1,2}, Victoria Chekusova ^{1,2}, Oleg Borshchev ^{1,2}, Alexey Vasiliev ^{2,3}, Elena Agina ^{1,2} and Sergey Ponomarenko ^{1,2,4}

- ¹ Enikolopov Institute of Synthetic Polymeric Materials of the Russian Academy of Sciences Profsoyuznaya, st. 70, 117393 Moscow, Russia; trul@ispm.ru (A.T.); chekusova@ispm.ru (V.C.); borshchev@ispm.ru (O.B.); agina@ispm.ru (E.A.); ponomarenko@ispm.ru (S.P.)
- ² Printed Electronics Technologies LLC, Profsoyuznaya st.70, Office 410, 117393 Moscow, Russia; a-a-vasiliev@yandex.ru
- ³ NRC Kurchatov Institute, Kurchatov Complex of Physical and Chemical Technologies, Akademika Kurchatova pl. 1, 123182 Moscow, Russia
- ⁴ Department of Chemistry Leninskie, Moscow State University, Gory 1–3, 119991 Moscow, Russia
- * Correspondence: sizov@ispm.ru; Tel.: +7-915-076-37-04
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Abstract: In this work gas sensing properties of Langmuir-Schaefer monolayer organic field-effect transistors (LS OFETs) prepared from organosilicon derivative of [1]benzothieno[3,2-b][1]-benzothiophene (BTBT) have been investigated. The monolayer has been deposited using Langmuir-Schaefer method, which results in a uniform low-defect monolayer with excellent electrical performance, hole mobility up to 7×10^{-2} cm² V⁻¹ s⁻¹, the threshold voltage around 0 V and on-off ratio of 10⁴. Developed sensors demonstrate a long-term stability of a half-year storage under ambient conditions. Preliminary investigations demonstrated that the LS OFETs give instantaneous response on ammonia and hydrogen sulfide at low concentrations. The results reported open new perspectives for the OFET-based gas-sensing technology.

Keywords: chemical sensing; OFETs; monolayer; Langmuir-Schaefer; organic electronics

1. Introduction

Organic field-effect transistors (OFETs) have garnered considerable attention because of their application in large-area, low cost and low power electronics [1]. The reliability of organic electronics devices still remains a crucial issue due to a strong sensitivity of organic semiconductors (OSCs) to chemical, optical and mechanical impacts, thus limiting the OFET technology commercialization as a competitor to traditional silicon electronics [2]. While such sensitivity is traditionally considered as a drawback, it simultaneously enables utilization of OFETs in various sensing applications, including chemical sensing. The number of OFET-based gas sensors reported up to date typically lack of air operation capability, selectivity to water and easily scalable fabrication technique [2,3].

In our work, we propose a self-assembled Langmuir-Schaefer monolayer field-effect transistor based on Langmuir-Schaefer monolayers of disiloxane derivative of benzothieno[3,2-b][1] benzothiophene (BTBT) (1,3-bis[11-(7-hexyl[1]benzothieno-[3,2-b][1]benzothien-2-yl)undecyl]-1,1,3,3-tetramethyldisiloxane) for chemical sensing (Figure 1) [4]. Selection of the semiconductor material is based on high charge carrier mobility demonstrated for BTBT molecules and high chemical stability of disiloxanes. The OSC monolayer has been deposited using Langmuir-Schaefer method. The conditions of uniform low-defect monolayer formation were found for this technique. Fabricated monolayers were used for preparation of OFET devices, which demonstrated excellent electrical performance with the hole mobility up to $7 \times 10^{-2} \text{ cm}^2 \text{ V}^{-1} \text{ s}^{-1}$, the threshold voltage around 0 V and on-

off ratio of 10⁴ as well as long-term stability of a half-year storage under ambient conditions. We demonstrated that the monolayer OFETs give instantaneous response on ammonia and hydrogen sulfide at low concentrations (Limit Of Detection (LOD) down to tens ppb). These findings show a great potential of Langmuir-Schaefer monolayer OFETs for large-area sensing devices application.



Figure 1. Langmuir-Schaefer monolayer organic field-effect transistors (LS OFETs) as chemical sensors: (**a**) The illustration of the working principle. An extremely low thickness of LS film (2–3 nm) enables both ultrafast sensor response and low LOD; (**b**) Chemical structure of 1,3-*bis*[11-(7-hexyl[1]benzothieno-[3,2-b][1]benzothien-2-yl)undecyl]-1,1,3,3-tetramethyldisiloxane.

2. Materials and Methods

2.1. OFETs Substrates

LS OFETs were prepared on heavily doped silicon substrates with thermally grown oxide SiO₂. The dielectric thickness was 200 nm, and its measured capacitance was 13 nF/cm². Gold source and drain electrodes were thermally evaporated through a shadow mask. The resulting bottom gate bottom contact configuration had fixed channel size of $W = 1000 \mu m$ and $L = 30 \mu m$.

2.2. Monolayer Deposition

The BTBT dimer has been synthesized as described before [4]. The monolayers have been deposited with Langmuir-Schaefer technique. The solution was prepared by dissolving the BTBT dimer in toluene (Acros, used as received) and spread on the water surface. Data were collected with a Nima 712BAM system equipped by a Brewster angle microscope MicroBAM2 using a Teflon trough and barriers at room temperature. The monolayers were compressed with the speed equal to 200 mm/min. LS films were obtained by horizontal transfer on silicon substrates, modified with octyldimethylchlorosilane (ODMS). Prior to electrical measurements the unwanted part of the OSC monolayer film was manually removed to prevent parasitic current. The LS OFETs fabricated were annealed at normal conditions during 72 h to remove water traces.

2.3. Sensor Properties

The sensors properties were tested in a specially designed Teflon chamber with a free volume of ~2.3 cm³. The LS OFET's response to toxic gases have been evaluated in dry air flow containing known amounts of NH₃ or H₂S diluted with the carrier gas generated by zero air generator (Khimelectronica, Russia). Mixtures of 200–5000 ppb of ammonia and hydrogen sulfide in carrier gas were prepared using computer driven GGS-K generator (Monitoring, Russia). The calibrated

permeation tubes (Monitoring, Russia) of NH₃ and H₂S were used. Mixtures of 10–200 ppb of toxic gases in dry air were prepared by additional diluting the GGS-K generator output with a synthetic air flow from a cylinder controlled by the mass-flow controller (Bronkhorst, The Netherlands). The electrical measurements were performed in a stabilized concentration that was reached after a 1 min flow.

3. Results and Discussion

The drain current (I_d) in a field-effect transistor in saturation mode can be described by the equation: [5]

$$I_{d}^{1/2} = \left(\frac{W}{2L}\mu C\right)^{1/2} \left(V_{g} - V_{T}\right),$$
(1)

where *L* and *W* are channel length and width respectively, V_g is a gate voltage, *C* is a dielectric capacitance per unit area. V_T and μ are the threshold voltage and charge carrier mobility of the device respectively. During the exposure of the device to small amounts of NH₃ or H₂S in dry air with both gate and drain voltages were kept at constant biases of -40 V. In these conditions the drain current in the device permanently decays, and the decay rate was found to be dependent on toxic gas concentration. The decay was empirically characterized by stretched exponent behavior:

$$I = I_0 exp\left(-t / \tau\right)^{\beta}, \qquad (2)$$

where β is a dispersion coefficient, dependent on the temperature, τ —characteristic relaxation time dependent on the toxic gas concentration. Typical dynamic response of the LS OFET sensor to 200 ppb H₂S is shown on Figure 2a. The decay rate in dry air ("zero" decay) should be attributed to bias stress effects in OFET. When H₂S is introduced into the cell, "zero" decay is combined with an extra effect of the toxic gas presence resulting in a current decay rate variation. As the toxic gas flow is turned off, the current slowly restores to the initial value. However, being affected by the gate bias stress, it continues to decrease. However, the device fully restores to the initial values after being kept dry air for 30–40 min without the applied voltage. The devices investigated demonstrate half-year storage under ambient conditions, which is a remarkable result for OFET-based chemical sensors.



Figure 2. Sensor properties of LS OFETs: (**a**) Dynamic response of the sensor to 200 ppb H₂S; (**b**) The statistical distribution of LOD to NH₃; (**c**) The statistical distribution of LOD to H₂S.

Figure 2b,c show the statistical distribution of LOD to NH₃ and H₂S correspondingly. The LS OFETs show high LOD reproducibility due to conditions of uniform low-defect monolayer. The lowest

LOD values for NH₃ and H₂S are 50 and 10 ppb correspondingly, which are among the best values reported for OFET gas sensors.

4. Conclusions and Outlook

To sum up, the sensing properties of Langmuir-Schaefer monolayer organic field-effect transistors (LS OFETs) prepared from organosilicon derivative of [1]benzothieno[3,2-b][1]-benzothiophene (BTBT) have been investigated. The monolayer has been deposited using Langmuir-Schaefer method, which results in a uniform low-defect monolayer with excellent electrical performance, hole mobility up to 7×10^{-2} cm² V⁻¹ s⁻¹, the threshold voltage around 0 V and on-off ratio of 10⁴. Developed sensors demonstrate a long-term stability of a half-year storage under ambient conditions. We demonstrated that the LS OFETs give instantaneous response on ammonia and hydrogen sulfide at low concentrations (LOD down to tens ppb). The work to correlate the variation of the OFET's parameters with the analyte type is currently in progress. The results reported open new perspectives for the OFET-based gas-sensing technology.

Author Contributions: E.A. and A.S. conceived and designed the experiments; O.B. synthesized the BTBT derivative; V.C. prepared sensor samples; A.T. performed the experiments and processed the data; S.P. and A.V. supervised the research; A.S. wrote the paper.

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Conflicts of Interest: The authors declare no conflict of interest.

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